

“Supporting Information”

Stabilization of *t*-ZrO₂ polymorph in glassy SiO₂ matrix at elevated temperatures accomplished by Ceria additions

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Contents:

Supplementary figure

- Fig. S1** XRD patterns of pure ZrO₂-SiO₂ system at two different temperatures.
- Fig. S2** FEG-Scanning electron micrograph of PZS.
- Fig. S3** Point EDS spectra recorded for CZS50 and CZS100.

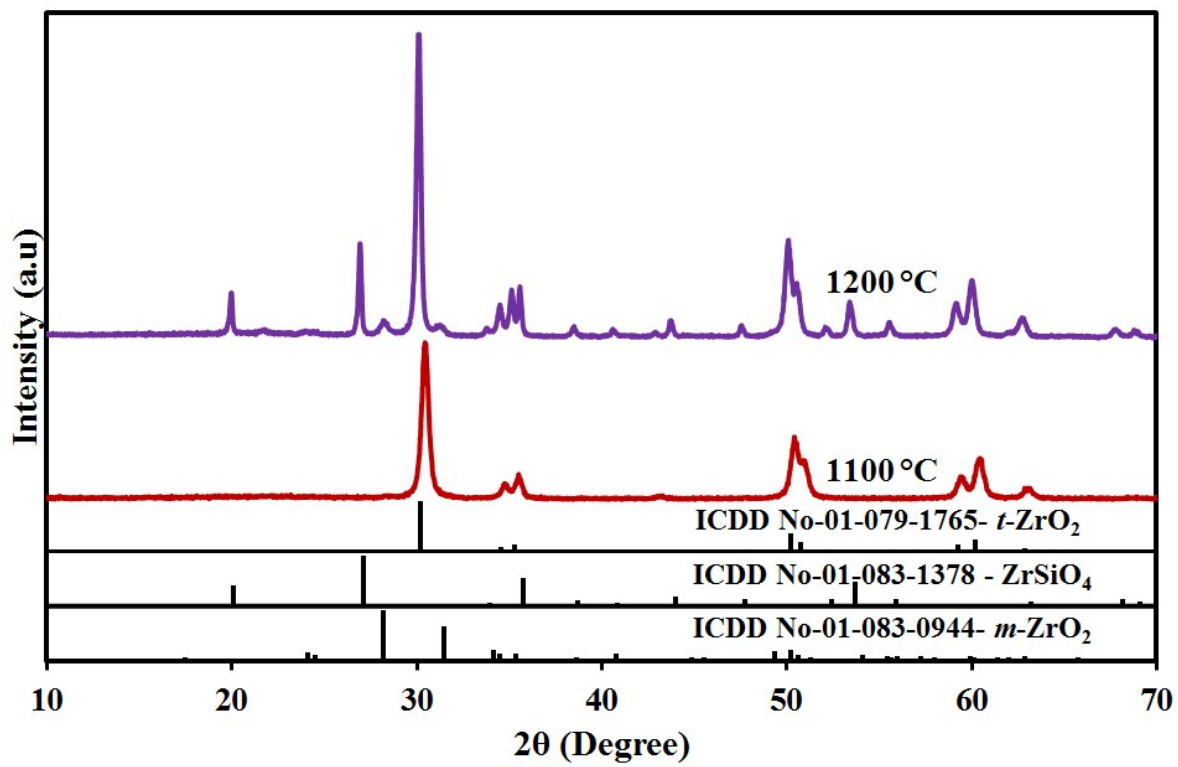


Fig. S1

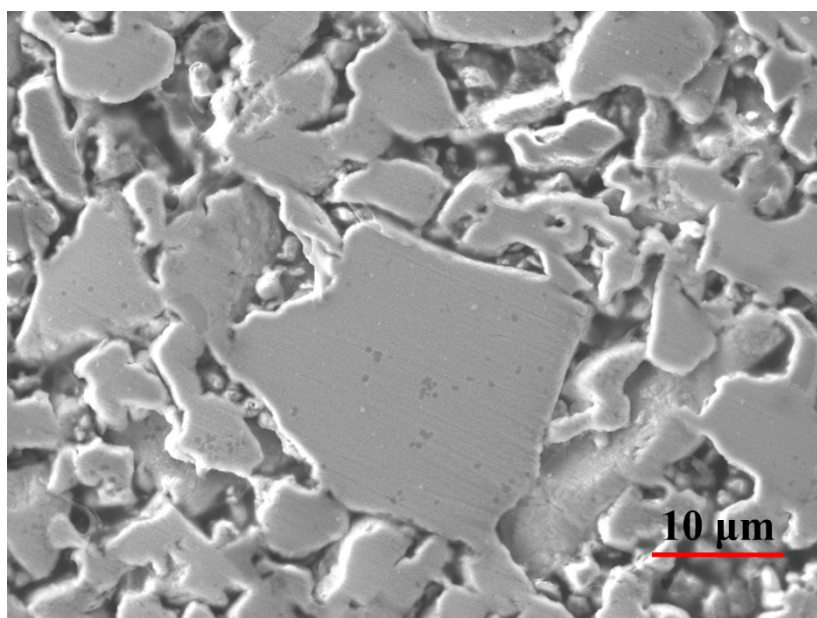
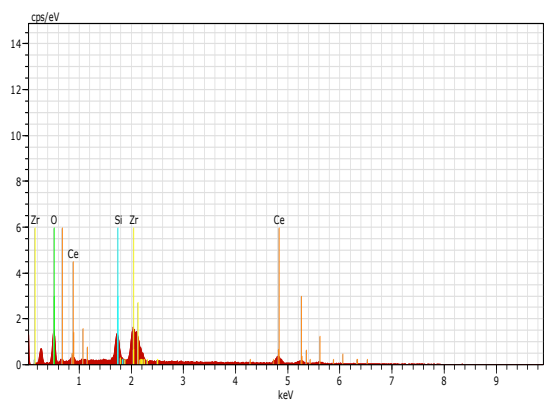
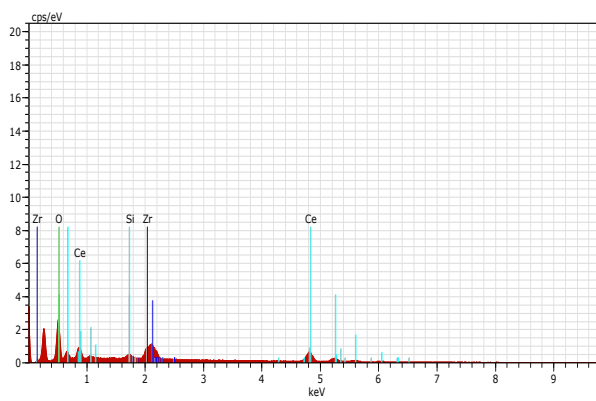


Fig. S2



CZS 50



CZS 100

Fig. S3